Electronic Supplementary Information for

Simulated revelation for the adsorption behaviours of

acetylcholinesterase on charged self-assembled monolayers

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 Table S1. The adsorption residues of TcAChE adsorbed on charged surfaces.

Fig. S1. Contact maps between TcAChE and charged SAMs during AAMD simulations: (A) 7% dissociated NH₂-SAM; (B) 7% dissociated COOH-SAM; (C) 25% dissociated NH₂-SAM; (D) 25% dissociated COOH-SAM.



Fig. S2. The time evolution of RMSD during overall processes of AAMD simulations.



Fig. S3. The hydrophobicity maps of TcAChE are shown in front and back views: the surface color changes from the blue for the strongest polar residue to orange-red for the most hydrophobic residue, with the intermediate residues in white.